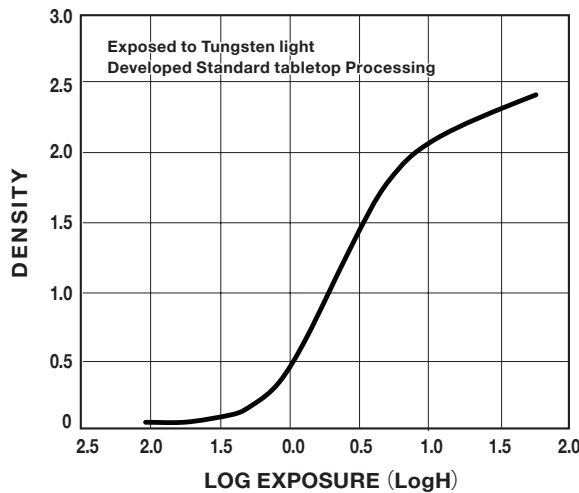


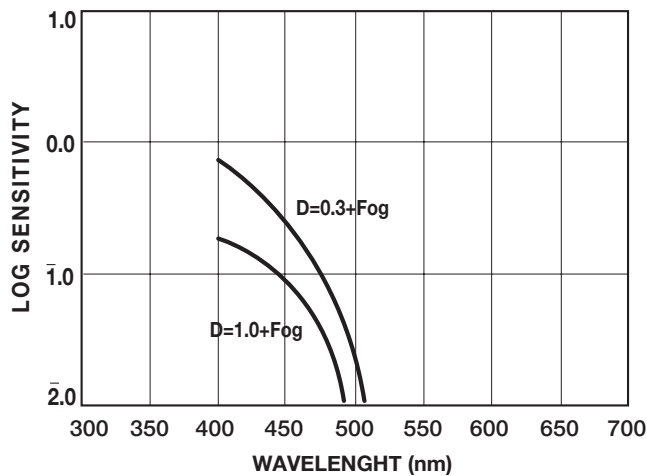
FUJIFILM MINIPOSITIVE II FILM

EXPOSURE INDEX	2.5 by Tungsten light exposure and standard microfilm processing. The exposure index is based on formula 45/E (M.C.S.) at a density of 1.2 above gross fog.	
COLOR SENSITIVITY	Blue (Regular type)	
SAFELIGHT	A safelight lamp should be equipped with Fujifilm safelight glass SLG2B (Red) and a 20-watt bulb, and should be kept at least four feet (1.2 meters) from the film.	
BASE USED	PET-100 Polyester Clear base 0.100 mm (4 mils)	
RESOLVING POWER	Test Object Contrast	Lines/mm
	1:1000	380
Measured on Fujifilm Resolution Tester Model FRE-1		

CHARACTERISTIC CURVE

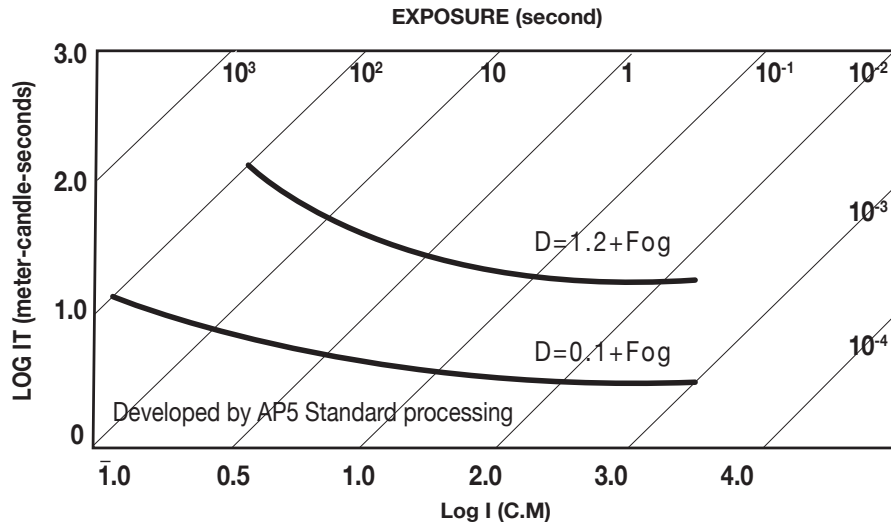


SPECTRAL SENSITIVITY CURVE

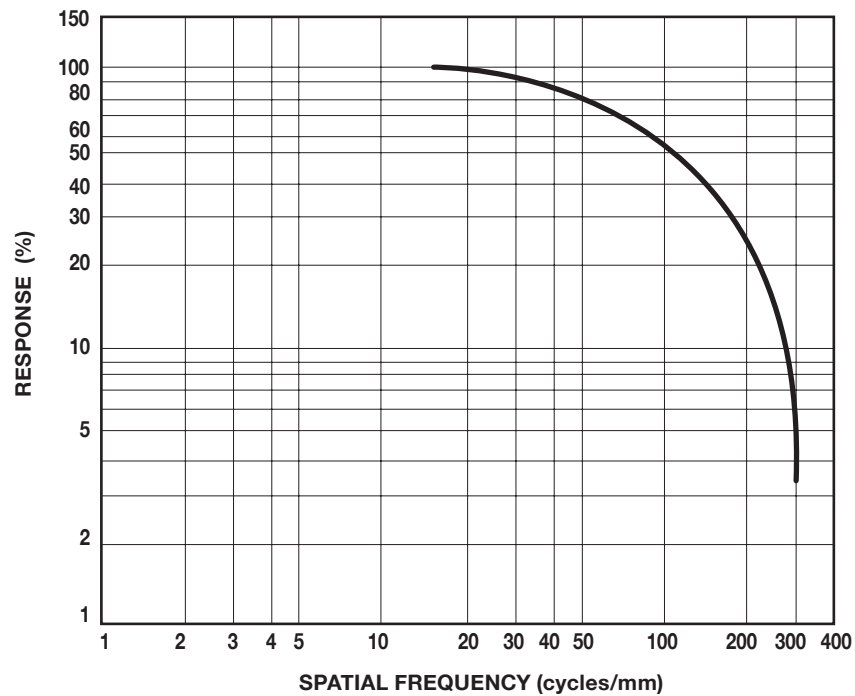


FUJIFILM MINIPOSITIVE II FILM

RECIPROCITY CURVE



MODULATION TRANSFER FUNCTION CURVE



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FUJIFILM North America Corporation
Industrial and Corporate
New Business Development Division

200 Summit Lake Drive
Valhalla, New York 10595-1356
1.800.755.3854
FujiFilmMicroFilm.com